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## Correction: Giant resistive switching in mixed phase BiFeO<sub>3</sub> via phase population control

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Correction for 'Giant resistive switching in mixed phase BiFeO<sub>3</sub> via phase population control' by David Edwards *et al.*, *Nanoscale*, 2018, **10**, 17629–17637.

The authors have noticed that the name of one of the co-authors was spelt incorrectly in the originally published version of this article. 'Sayed O. Sayedghaee' should have been spelt 'Sayed O. Sayedaghaee' as provided in the corrected author list above.

The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

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